

# BNL-94482-2010-TECH EIC/34;BNL-94482-2010-IR

# Copper coating specification for the RHIC arcs

M. Blaskiewicz,

December 2010

Collider Accelerator Department Brookhaven National Laboratory

# **U.S. Department of Energy**

USDOE Office of Science (SC)

Notice: This technical note has been authored by employees of Brookhaven Science Associates, LLC under Contract No.DE-AC02-98CH10886 with the U.S. Department of Energy. The publisher by accepting the technical note for publication acknowledges that the United States Government retains a non-exclusive, paid-up, irrevocable, world-wide license to publish or reproduce the published form of this technical note, or allow others to do so, for United States Government purposes.

## DISCLAIMER

This report was prepared as an account of work sponsored by an agency of the United States Government. Neither the United States Government nor any agency thereof, nor any of their employees, nor any of their contractors, subcontractors, or their employees, makes any warranty, express or implied, or assumes any legal liability or responsibility for the accuracy, completeness, or any third party's use or the results of such use of any information, apparatus, product, or process disclosed, or represents that its use would not infringe privately owned rights. Reference herein to any specific commercial product, process, or service by trade name, trademark, manufacturer, or otherwise, does not necessarily constitute or imply its endorsement, recommendation, or favoring by the United States Government or any agency thereof or its contractors or subcontractors. The views and opinions of authors expressed herein do not necessarily state or reflect those of the United States Government or any agency thereof.

C-A/AP/#413 Dec 2010

# **Copper Coating Specification for the RHIC Arcs**

M. Blaskiewicz



# Collider-Accelerator Department Brookhaven National Laboratory Upton, NY 11973

Notice: This document has been authorized by employees of Brookhaven Science Associates, LLC under Contract No. DE-AC02-98CH10886 with the U.S. Department of Energy. The United States Government retains a non-exclusive, paid-up, irrevocable, world-wide license to publish or reproduce the published form of this document, or allow others to do so, for United States Government purposes.

### Copper coating specification for the RHIC arcs

## M. Blaskiewicz<sup>\*</sup>

BNL, Upton NY 11973, USA

Copper coating specifications for the RHIC arcs are given. Various upgrade scenarios are considered and calculations of resistive wall losses in the arcs are used to constrain the necessary quality and surface thickness of a copper coating [1]. We find that 10  $\mu$ m of high purity copper will suffice.

#### I. INTRODUCTION AND THEORY

Typical parameters for an eRHIC [2] are shown in Table I. We will be concerned with ohmic losses on the pipe walls. For a round beam pipe the power loss per meter is given by [3]

$$P' = \frac{MQ^2}{4\pi^2 bT_0} \int\limits_0^\infty d\omega R_s(\omega) e^{-\sigma_s^2 \omega^2/c^2},$$
(1)

where  $R_s(\omega)$  is the surface resistivity as a function of angular frequency. For room temperature and low frequencies  $R_s = \sqrt{Z_0 \omega \rho/2c}$ , where  $Z_0 = \mu_0 c = 377\Omega$ . Room temperature resistivities give ohmic losses of 0.5 W/m for a stainless steel beam pipe and 0.12 W/m for a copper one. The previously used upper limit for losses in the arcs is 0.5 W/m [4]. Cooling the stainless steel pipe to 4K will reduce it's resistivity but magneto-resistance will increase it. It therefore seems prudent to reduce the ohmic losses by coating the beam pipe with copper. A device for insitu coating is described in [1] and previous calculations have assumed that one can count on a factor of RRR=100 reduction in resistivity leading to a coating thickness of  $5\mu$ m. There are two problems with this procedure. Firstly, magneto-resistance at 3.45T and an RRR of 100 doubles the effective resistivity of the copper [5]. Secondly, even with an effective RRR=50, the mean free path of an electron in the copper is  $\ell = 2\mu$ m, which is the skin depth at 20 MHz. This was estimated using the formula [3]  $\ell = (\rho_0 \ell_0)/\rho$  where  $\rho_0 \ell_0 = 6.6 \times 10^{-16} \Omega m^2$  for copper. When the mean free path is longer than the skin depth the current at one location in the metal will be influenced by significantly different electric fields at other locations and one needs to include convection in the electron transport [6]. This calculation was done in [6] for a ray of light with normal incidence. For wavenumber  $k = \omega/c$  the electric field satisfies

$$\frac{d^2 E}{dr^2} + k^2 E = \frac{-3iZ_0 k}{4\rho\ell} \int_0^d dr_1 E(r_1) k_a \left(\frac{r-r_1}{\ell}\right)$$
(2)

#### TABLE I: RHIC ring parameters

parameter	value
circumference	$C = 3834 \mathrm{m}$
revolution period and frequency	$T_0 = 12.8 \ \mu s = 1/f_0$
maximum charge per bunch	$Q = 32 \mathrm{nC}$
minimum rms bunch length	$\sigma_s=5~{ m cm}$
bunches in the ring	M = 180
room temperature copper resistivity	$ \rho_c = 1.7 \times 10^{-8} \ \Omega \mathrm{m} \ [7] $
RRR for copper	100
room temperature stainless resistivity	$ ho_s=3.6 imes10^{-7}~\Omega{ m m}$
beam pipe radius	b = 3.6  cm

\*Electronic address: blaskiewicz@bnl.gov

where r measures the depth of the material, d is the thickness of the coating, and we have assumed diffuse reflection of the electrons at the interface as verified by measurements [8]. The time dependence is  $\exp(-i\omega t)$  and the kernel function is

$$k_a(x) = \int_{1}^{\infty} e^{-|x|sa} \left(\frac{1}{s} - \frac{1}{s^3}\right) ds,$$

where  $a = 1 - i\omega \ell / v_{fermi}$  and the Fermi velocity is  $v_{fermi} = 1.57 \times 10^6 \text{m/s}$  for copper. Note that

$$\int\limits_{-\infty}^{\infty} dx k_a(x) = 4/3a,$$

so that if the electric field is constant over many mean free paths equation (2) reduces to

$$\frac{d^2E}{dr^2} + k^2 E = -i\mu_0 \omega J(r), \tag{3}$$

with  $J = \sigma E/a$  where  $\sigma = 1/\rho$  is the low frequency conductivity. This result was in fact used to obtain the coefficient in (2).

The surface impedance is  $Z_s = E/H$  where  $H = B/\mu_0$  for our nonmagnetic materials and the fields are evaluated at the surface of the material. Faraday's law in cylindrical coordinates gives

$$\frac{\partial E_r}{\partial z} - \frac{\partial E_z}{\partial r} = i\omega\mu_0 H_\phi.$$

For beam generated fields with  $J = \sigma E$  in the wall of a cylindrical pipe, the second term on the left is much bigger than the first [9] giving

$$Z_s \approx -ikZ_0 \frac{E_z}{E_z'},$$

where  $E'_z = \partial E_z / \partial r$  evaluated at the surface and  $Re(Z_s) = R_s(\omega)$  in equation (1). This is the same result one gets for the reflection of normally incident light which allows us to use the same expressions for surface impedance in both cases. For  $d \to \infty$  equation (2) can be solved in closed form using Laplace transforms [10] and expressions for the surface impedance may be obtained. One finds

$$\frac{E'_z}{E_z} = -\frac{a}{\pi\ell} \int_0^\infty \ln\left\{1 + \frac{\xi\chi(t)}{t^2}\right\} dt,\tag{4}$$

where the fields are evaluated at the surface of the metal,  $\xi = 3\ell^2/2\delta^2 a^3$ ,  $\delta = \sqrt{2\rho/kZ_0}$  is the skin depth and  $\chi(t) = 2t^{-3}[(1+t^2)\arctan(t) - t] = 4/3 + 4t^2/15 + O(t^4)$ . While equation (2) holds for diffuse reflection of electrons of the metal surface it is possible to solve the kinetic equations assuming electrons undergo perfect reflection at the interface. In this case

$$\frac{E_z}{E_z'} = -\frac{2\ell}{\pi a} \int_0^\infty \frac{dt}{t^2 + \xi\chi(t)}.$$
(5)

In equations (4) and (5) r is zero at the interface between vacuum and copper and increases with depth in the copper. This produces a sign change in the derivatives which is simple but needs to be looked after.

When the coating thickness is finite one may solve equation(2) numerically. To do this first take the dimensionless variable  $u = r/\ell$ . Next we take u = 0 to be at the interface between the copper and the stainless steel. Equation (2) becomes

$$\frac{d^2E}{du^2} + k^2 \ell^2 E = -iA \int_0^{d/\ell} du_1 E(u_1) k_a(u - u_1)$$
(6)

where  $A = 3Z_0 k\ell^2/4\rho$ . Inside the stainless for u < 0 one has  $E(u) = E_0 \exp[(1-i)u\ell/\delta_{ss}]$  where  $\delta_{ss}$  is the skin depth in the stainless and  $E_0$  is a constant. Since  $E_z$  and  $H_{\phi}$  are continuous at the boundary one has  $E(u) = E_0 + uE_0(1-i)\ell/\delta_{ss} + O(u^2)$  for small positive u inside the copper. Integrating equation (6) twice with respect to u gives

$$E(u) + \int_{0}^{u} (u - u_2) du_2 \left( k^2 \ell^2 E(u_2) + iA \int_{0}^{d/\ell} du_1 E(u_1) k_a(u_2 - u_1) \right) = E_0 + uE'_0, \tag{7}$$

where  $E'_0 = E_0(1-i)\ell/\delta_{ss}$ . To evaluate the surface impedance for thick copper coatings equations (4) and (5) may be evaluated numerically. To understand the effect of coating thickness we need to solve equation (7) numerically. To do this set  $d/\ell = \hat{d}$  and divide the interval  $[0, \hat{d}]$  into K equal segments of length  $\Delta = \hat{d}/K$ . Let  $E_m = E(u_m)$  be the field at  $u_m = [m - 1/2]\Delta$  for m = 1, 2, ...K. The term in (7) proportional to  $k^2\ell^2$  is extremely small and will be dropped leaving

$$E_n + iA\Delta^3 \sum_{j=1}^K E_j \sum_{m=1}^n (n-m)\hat{k}_a(m-j) = E_0 + E_0'(n-1/2)\Delta.$$
(8)

where we have defined a smoothed version of  $k_a(x)$  namely

$$\hat{k}_a(x) = rac{1}{\Delta} \int\limits_{x-\Delta/2}^{x+\Delta/2} dx_1 k_a(x_1).$$

The smoothing makes  $\hat{k}_a(0)$  finite and equation (8) can now be solved via matrix inversion.

Before closing this section we note that a quantum mechanical theory of the anomalous skin effect exists [11]. This theory produces the smoothing function  $\exp(-|x|/\ell)$ . For large r,  $k_a(r/\ell) = 2\exp(-a|r|/\ell)/(a|r|/\ell)^2$ 

### II. RESULTS

Figures 1 through 4 show solutions of equation (8) for two frequencies. The value of RRR = 50 used in the calculation corresponds to 3.45T. For these figures the electric field is set to one at u = 0. From Figure 1 it is seen that the electric field at 10 MHz has a magnitude greater than 10 at the surface of the metal. Therefore, the effective surface current at the stainless steel is less than 1/10th the surface current at the pipe wall and the dissipation in the stainless steel is less than 1% of what it would be without copper coating. For the high frequency case the field in the stainless is much smaller. This plot is included to show that  $k_a$  begins to have an imaginary part only at very high frequencies.

Figures 5 and 6 show surface impedance calculations using equations (4) and (8) for RRR = 50 and RRR = 25 respectively. Using equation (1) and the beam parameters in Table 1, the power per unit frequency for the two values of RRR are shown in Figure 7. For RRR = 50 at 3.45T the power per unit frequency is 0.064 Watts/meter. For RRR = 25 at 3.45T the power per unit frequency is 0.079 Watts/meter. Both the values are well below the 0.5 Watt/meter) limit considered in [4]. For a fixed bunch length of  $\sigma_s = 5$  cm the results are easily extended to different numbers of bunches and charges per bunch. For instance, with  $1.0 \times 10^{11}$  protons per bunch the charge per bunch is 16 nC. For 2000 such bunches and RRR = 50 the loss rate is  $P = (1/2)^2 (2000/180) 0.064$  Watts/meter = 0.18 Watts/meter which is still acceptable.

### Acknowledgements

Thanks to Wolfram Fischer for useful discussions and encouragement. Slides provided by Elias Metral were very helpful.

 A. Hershcovitch, M. Blaskiewicz, J.M. Brennan, W. Fischer, C-J Liaw, W. Meng, A. Custer, M. Erickson, N. Jamshidi, H.J. Poole, IPAC10, p1509, tupea082, (2010).



FIG. 1: Electric field with stainless steel for r < 0 and copper with RRR = 50 for  $0 < r < 10 \mu m$ . The frequency is 10 MHz.



FIG. 2: The function  $\hat{k}_a(r/\ell)$  for the parameters in Figure 1.

- [2] V. Litvinenko wexmh02 IPAC10 (2010).
- [3] W. Chou, F. Ruggiero, LHC Project Note 2 (SL/AP) (1995).
- [4] A.G. Ruggiero, S. Peggs RHIC/AP/46 (1994).
- [5] F. Caspers et. al. LHC Project report # 307, (1999).
- [6] G.E.H Reuter and E.H. Sondheimer Proc. R. Soc. London A 195 p336 (1948).
- [7] CRC Handbook of chemistry and physics. section 12-232.
- [8] R.G. Chambers Proc. R. Soc. London A 215 p481 (1952).
- [9] Chao's book



FIG. 3: Electric field with stainless steel for r < 0 and copper with RRR = 50 for  $0 < r < 10 \mu$ m. The frequency is 10 GHz.



FIG. 4: The function  $\hat{k}_a(r/\ell)$  for the parameters in Figure 3.

- [10] R.B. Dingle *Physica* **19** p311 (1953).
- [11] D.C. Mattis and J. Bardeen Phys. Rev. 111 # 2 p412 (1958).



FIG. 5: Surface resistance calculations for RRR = 50 with  $10\mu$ m of copper using (8) are displayed with blue dots. The red line used equation (4).



FIG. 6: Surface resistance calculations for RRR = 25 with  $10\mu$ m of copper using (8) are displayed with blue dots. The red line used equation (4).



FIG. 7: Ohmic loss per unit length per unit frequency using equation (4) and (1). For RRR = 50 the integral is 0.064 Watts/m. For RRR = 25 the integral is 0.079 Watts/m.